

Tuesday, December 7

8:00	Registration
9:00-9:25	Opening
9:25-10:10 Invited	Alexander Vahl , CAU Kiel, Germany "Reactive sputter deposition for functional thin films: From photocatalysis to bio-inspired electronic devices"
10:10-10:35	oral 1
10:35-10:55	coffee break
10:55 -11:20	oral 2
11:20-11:45	oral 3
11:45-12:10	oral 4
12:10-13:00	lunch break and poster session
13:00-13:45 Invited	Daniel Lundin, Linköping University, Sweden " <i>Optimizing Ionization and Deposition Rate in High Power Impulse Magnetron Sputtering</i> "
13:45-14:10	oral 5
14:10-14:35	oral 6
14:35-15:45	coffee break and poster session
15:45-16:10	oral 7
16:10-16:35	oral 8
16:35-17:00	oral 9
18:00-22:00	conference dinner

Wednesday, December 8

8:00	Registration
9:00-9:45 Invited	Tomas Kozak, University of West Bohemia, Pilsen, Czech Republic <i>"Modelling reactive HiPIMS: coupling surface and discharge models and connecting with experiments"</i>
9:45-10:10	oral 10
10:10-10:35	oral 11
10:35-10:55	coffee break
10:55 -11:20	oral 12
11:20-11:45	oral 13
11:45-12:10	oral 14
12:10-13:00	lunch break
13:00-13:45 Invited	Sebastian Ekeröth, Linköping University, Sweden <i>"High-power pulsed hollow cathode sputtering for growth of complex nanoparticles and nanostructures"</i>
13:45-14:10	oral 15
14:10-14:35	oral 16
14:35-14:45	closing ceremony